

APPROVED	O.G. FIG.	
BY	CLASS	SUBCLASS
DRAFTSMAN		

Title: METHODS, COMPLEXES, AND SYSTEMS FOR FORMING METAL-CONTAINING FILMS ON SEMICONDUCTOR STRUCTURES

Applicant(s): [REDACTED] Vaartstra

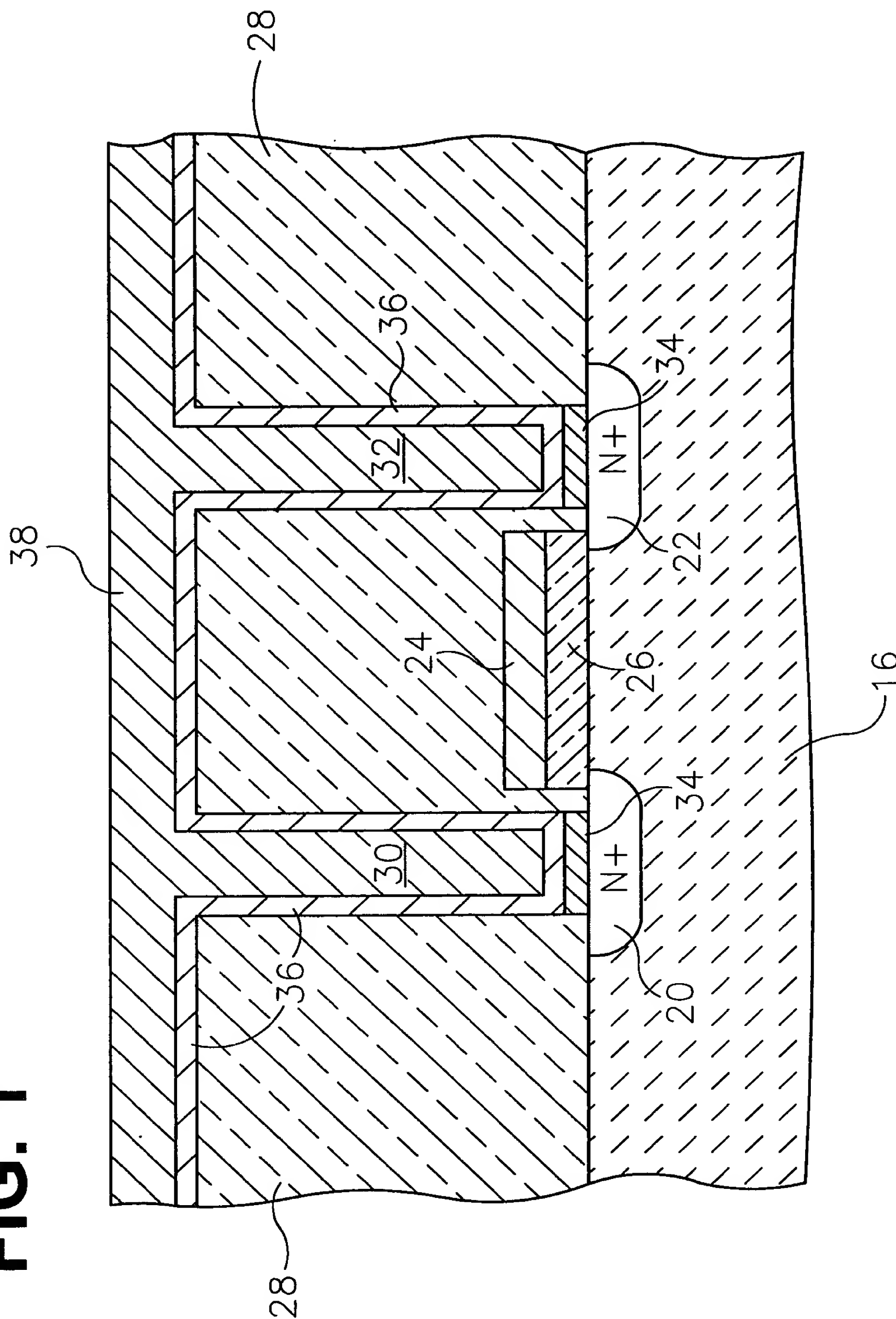
Serial No.: Not Assigned

Filed: Herewith

Docket: 15cr00081 0102

Sheet 1 of 3

FIG. 1



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Express Mail No.: EL776903676US

Docket: 150000000102

Sheet 2 of 3

FIG. 2

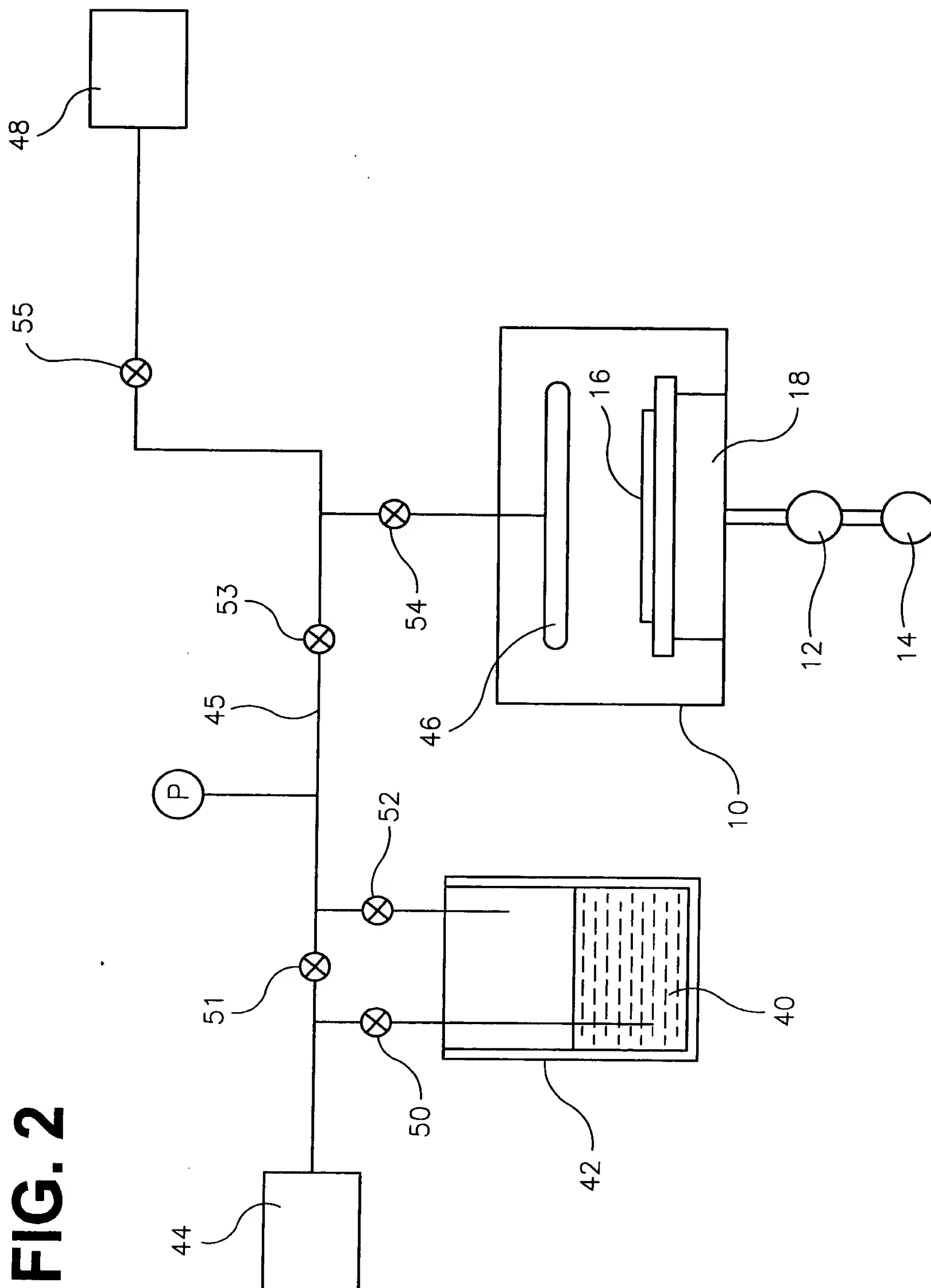


FIG. 3

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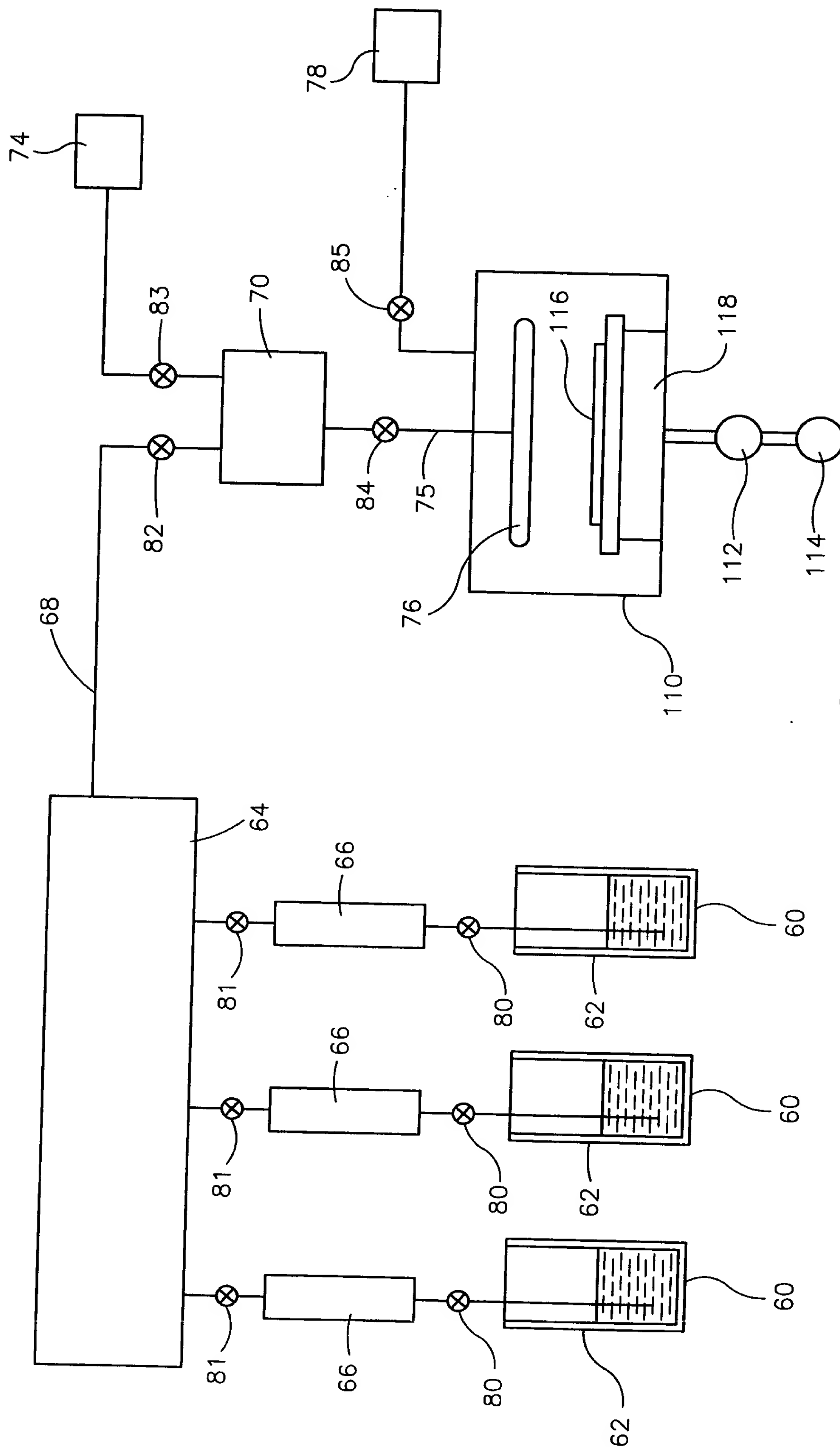


FIG. 3